WHAT IS CLAIMED IS;

1	1. A method for the formation of rectifying junctions on alloy-semiconductors
2	comprising the steps of:
3	photo-electrochemical removal of one component of the alloy material and
4	chemical etching of another component of the alloy
5	to produce a positive-intermediate-negative (PIN) structure semiconductor.
1	2. The method according to Claim 1, wherein the alloy semiconductor comprises
2	a combination of Group II element and a Group VI element.
1	3. The method according to Claim 2, wherein the alloy semiconductor comprises
2	CdTe.
1	4. The method according to Claim 2, wherein the alloy semiconductor comprises
2	CdZnTe.
1	5. The method according to Claim 2, wherein the alloy semiconductor comprises
2	HgZnCdTe.
1	6. The method according to Claim 2, wherein the alloy semiconductor comprises
2	HgCdZnSe.
1	7. A method for the formation of rectifying junctions on alloy-semiconductors
2	comprising the steps of:
3	photo-electrochemical removal of one component of the alloy material to produce one
4	portion of the junction and
5	deposition of a second component to produce a second portion of the junction
6	to produce a positive-intermediate-negative (PIN) structure semiconductor.

semiconductor comprises CdZnTe.

semiconductor comprises HgZnCdTe.

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The method according to Claim 7, wherein the alloy semiconductor comprises

The PIN structure semiconductor according to Claim 14, wherein the alloy

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HgZnCdTe.

- 1 24. The device according to Claim 20, wherein the alloy semiconductor comprises
- 2 HgCdZnSe.

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